

3D LASER LITHOGRAPHY FACILITY AND SEM FACILITY

Charges for using 3D Laser Lithography Facility					
S. No.	Usage	IITB Users (Rs.)	External Academic Institutions	National Labs and R&D Organizations	Users from Industry
1	Equipment usage fee	500	1500	2000	5000
2	3D designing charges	500	1500	2000	5000
3	2D structure(1 cm ²)	250	750	1000	2500
4	2D structure with SEM (1 cm ²)	450	1350	1800	5000
5	3D structure (height up to 300 um)	500	1500	2000	5000
6	3D structure with SEM (height up to 300 um)	700	2100	2800	7500
7	3D structure (height up to 1 mm)	1500	4500	6000	15000
8	3D structure with SEM (height up to 1 mm)	1700	5100	6800	17500
9	Hourly fee if fabrication takes longer than 1 hour	500	1500	2000	3000
Charges for using Scanning Electron Microscope Facility					
Imaging		250 / sample	700 / sample	1500 / sample	2500 / sample

Additional charges:

- 18% GST
- Substrate charge: Rs. 500/- per substrate (for 3D Laser Lithography)
- Charges for optimizing writing parameters - Substrate cost plus writing cost on an hourly basis (excluding usage fee) (for 3D Laser Lithography)